

IDS Form PTO/SB/08: Substitute for form 1449A/PTO SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as necessary)				Complete if Known	
				Application Number	10/590,475
				Filing Date	June 28, 2007
				First Named Inventor	Atsushi MAE et al.
				Art Unit	2621
				Examiner Name	Nguyen, Huy Thanh
Sheet	1	of	1	Attorney Docket Number	09812.0139

U.S. PATENTS AND PUBLISHED U.S. PATENT APPLICATIONS					
Examiner Initials [*]	Cite No. ¹	Document Number	Issue or Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code ² (if known)			

Note: Copies of the U.S. Patent Documents are not Required in IDS filed after October 21, 2004

FOREIGN PATENT DOCUMENTS						
Examiner Initials [*]	Cite No. ¹	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Translation ⁶
		Country Code ³ Number ⁴ Kind Code ⁵ (if known)				

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials [*]	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Translation ⁶
/H.N./		European Application No. 05814155.7, Summons to Attend Oral Proceedings Pursuant to Rule 115(1) EPC, mailed July 2, 2010, received July 7, 2010 (6 pages).	
/H.N./		"Learning about your computer MS-DOS," MS-DOS User's Guide and Reference, April 10, 1998, XP002914919 (28 pages).	

Examiner Signature	/Huy Nguyen/	Date Considered	11/22/2010
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.